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ABSTRACT

ACRYLIC MONOMER, POLYMER, AND CHEMICALLY AMPLIFIED PHOTORESIST COMPOSITION

Disclosed are an acrylic monomer, a polymer, and a chemically amplified photoresist composition. The acrylic monomer has a t-butoxycarbonyl group (t-BOC group) at its distal end. The acrylic monomer is used as a raw material of the polymer constituting the chemically amplified photoresist composition.

Figure for publication: None